

RO3000[®] Series Circuit Materials RO3003[™], RO3006[™], RO3010[™] and RO3035[™] High Frequency Laminates

RO3000° high frequency circuit materials are ceramic-filled PTFE composites intended for use in commercial microwave and RF applications. This family of products was designed to offer exceptional electrical and mechanical stability at competitive prices.

RO3000 series laminates are ceramic-filled PTFE based circuit materials with mechanical properties that are consistent regardless of the dielectric constant selected. This allows the designer to develop multi-layer board designs that use different dielectric constant materials for individual layers, without encountering warpage or reliability problems.

RO3000 materials exhibit a coefficient of thermal expansion (CTE) in the X and Y axis of 17 ppm/°C. This expansion coefficient is matched to that of copper, which allows the material to exhibit excellent dimensional stability, with typical etch shrinkage (after etch and bake) of less than 0.5 mils per inch. The Z-axis CTE is 24 ppm/°C, which provides exceptional plated through-hole reliability, even in severe thermal environments. The dielectric constant versus temperature for RO3003[™] and RO3035[™] materials is very stable (Chart 1).

RO3000 series laminates can be fabricated into printed circuit boards using standard PTFE circuit board processing techniques, with minor modifications as described in the application note "Fabrication Guidelines for RO3000 Series High Frequency Circuit Materials."

R03000 laminates are manufactured under an ISO 9001 certified system.





Data Sheet



FEATURES AND BENEFITS: Low dielectric loss (RO3003™ laminates)

- Laminates can be used in applications up to 77 GHz. Excellent mechanical properties
- versus temperature
- Reliable stripline and multi-layer board constructions.

Uniform mechanical properties for a range of dielectric constants

- Ideal for multi-layer board designs with a range of dielectric constants
- Suitable for use with epoxy glass multi-layer board hybrid designs

Stable dielectric constant versus temperature and frequency (RO3003 laminates)

 Ideal for band pass filters, microstrip patch antennas, and voltage controlled oscillators.

Low in-plane expansion coefficient (match to copper)

- Allows for more reliable surface mounted assemblies
- Ideal for applications sensitive to temperature change
 Eventuate dimensional atability

• Excellent dimensional stability

- Volume manufacturing process
 - Economical laminate pricing

Some Typical Applications:

- Automotive radar applications
- Global positioning satellite antennas
- Cellular telecommunications systems - power amplifiers and antennas
- Patch antenna for wireless communications
- Direct broadcast satellites
- Datalink on cable systems
- Remote meter readers
- Power backplanes









Chart 1: R03003 and R03035 Laminate Dielectric Constant vs. Temperature

Chart 2: R03003 and R03035 Dissipation Factor

The data in Chart 2 shows the distribution of dissipation factor for R03003 and R03035 materials.

Test Method: IPC-TM-650 2.5.5.5 Condition: 10 GHz 23° C





1.05 1.04 1.03 Normalized Dk ← RO3003[™] laminate ← RO3035[™] laminate 1.02 - RO3006[™] laminate 1.01 --- RO3010[™] laminate High Performance FR-4 1.00 0.99 0.98 10 50 Frequency (GHz)

Chart 3 demonstrates the stability of dielectric constant for R03000 series products over frequency. This stability simplifies the design of broadband components as well as allowing the materials to be used in a wide range of applications over a very broad range of frequencies.



Data Sheet

Property	Typical Value ⁽¹⁾							
	RO3003	RO3035	RO3006	RO3010	Direction Unit	Condition	Test Method	
Dielectric Constant, ε _r Process	3.00 ± 0.04	3.50 ± 0.05	6.15 ± 0.15	10.2 ± 0.30	Z	-	10 GHz 23°C	IPC-TM-650 2.5.5.5 Clamped Stripline
$^{(2)}\mbox{Dielectric Constant,}\epsilon_{\rm r}$ Design	3.00	3.60	6.50	11.20	Z	-	8 GHz - 40 GHz	Differential Phase Length Method
Dissipation Factor, tan $\boldsymbol{\delta}$	0.0010	0.0015	0.0020	0.0022	Z	-	10 GHz 23°C	IPC-TM-650 2.5.5.5
Thermal Coefficient of ϵ_r	-3	-45	-262	-395	Z	ppm/°C	10 GHz -50 to 150°C	IPC-TM-650 2.5.5.5
Dimensional Stability	-0.06 0.07	-0.11 0.11	-0.27 -0.15	-0.35 -0.31	X Y	mm/m	COND A	IPC TM-650 2.2.4
Volume Resistivity	107	107	10⁵	105		MΩ•cm	COND A	IPC 2.5.17.1
Surface Resistivity	107	107	105	10 ⁵		MΩ	COND A	IPC 2.5.17.1
Tensile Modulus	900	1015	2068	1500	Х, Ү	MPa	23°C	ASTM D638
Moisture Absorption	0.04	0.04	0.02	0.05	-	%	D48/50	IPC-TM-650 2.6.2.1
Specific Heat	0.9		0.86	0.8		J/g/K		Calculated
Thermal Conductivity	0.50	0.50	0.79	0.95	-	W/m/K	50°C	ASTM D5470
Coefficient of Thermal Expansion	17 16 25	17 17 24	17 17 24	13 11 16	X Y Z	ppm/°C	-55 to 288°C	ASTM D3386-94
Td	500	500	500	500		⁰C TGA		ASTM D3850
Density	2.1	2.1	2.6	2.8		gm/ cm³	23°C	ASTM D792
Copper Peel Strength	12.7	10.2	7.1	9.4		lb/in	1 oz. EDC After Solder Float	IPC-TM-2.4.8
Flammability	V-0	V-0	V-0	V-0				UL 94
Lead Free Process Compatible	YES	YES	YES	YES				

NOTES:

RoHS Compliant (1) Typical values are a representation of an average value for the population of the property. For specification values contact Rogers Corporation.

(2) The design Dk is an average number from several different tested lots of material and on the most common thickness/s. If more detailed information is required, please contact Rogers Corporation or refer to Rogers' technical papers in the Roger Technology Support Hub available at http://www.rogerscorp.com/acm/technology.



Data Sheet

Standard Thickness	Standard Panel Size	Available Copper Cladding			
R03003/R03035: 0.005" (0.13mm) 0.010" (0.25mm) 0.020" (0.50mm) 0.030" (0.75mm) 0.060" (1.52mm)	12" X 18" (305 X 457mm)	¼ oz. (9µm) electrodeposited copper foil (HQ/HQ)			
	24" X 18" (610 X 457mm)	${\rm 1}{\rm 2}$ oz. (17µm) electrodeposited copper foil (HH/HH)			
		1 oz. (35µm) electrodeposited copper foil (H1/H1)			
		2 oz. (70µm) electrodeposited copper foil (H2/H2)			
0.000 (1.521111)		$\ensuremath{^{1\!\!/}}$ oz. (17µm) reverse treated electrodeposited cu foil (SH/SH)			
RO3006/RO3010: 0.005" (0.13mm)		1 oz. (35µm) reverse treated electrodeposited cu foil (S1/S1)			
0.010" (0.25mm)		2 oz. (70µm) reverse treated electrodeposited cu foil (S2/S2)			
0.025" (0.64mm) 0.050" (1.28mm)					
0.050 (1.2000)		R03003 & R03035 laminates also available with ½, 1 and 2 oz. rolled copper foil			
		R03003 5 mil thick laminates also available with 6 oz. rolled copper foil and 0.040" rolled copper plate			
		Other claddings may be available. Contact customer service.			

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